FORM PTO-1449

U.S. DEPARTMENT OF COMMERCE PARENT TRADEMARK OFFICE

SHEET <u>1</u> OF <u>2</u> (REV. 7-80)

LIST OF REFERENCES CITED BY APPLICANT

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DOCKET NO.: APPLICANT:

5407/0J061

Walter Brieden, et al.

SERIAL NO:

09/198,427

FILING DATE:

4/12/98

CONFIRMATION NO: 2487

U.S. PATENT DOCUMENTS

*EXAMINER <u>INITIALS</u>	2	DOCUMENT NUMBER	<u>DATE</u>	NAME I	FILING DATE	<u>CLAS</u>	SUBCLASS
MM	1.	5,034,394	7/23/91	Daluge	12/22/89	514	261
	2.	5,294,423	3/15/94	Lorthioir et al	. 4/24/92	423	286
1	3.	5,200,527	4/6/93	Griffiths et al	. 4/1/92	548	452

FOREIGN PATENT DOCUMENTS

*EXAMINER INITIALS	DOCUMENT NUMBER	DATE COUNTRY	CLASS SUBCLASS	TRANSLATION YES NO
	5. 512,895-A	4/29/92 EP 8/25/56 DE	C01B 6/21	X (Abstract)
MM 6	5. 93/17020 <i>-</i> 7. 508,352- B1'	9/2/93 WO 4/6/92 EP	C07D 473/00 C07D 221/22	X X (Abstract)
1V 8	3. 95/21161 ·	8/10/95 WO	C07D 239/48	X

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*EXAMINER:

Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.